

Amendments

In the Drawings:

In Fig. 4A, please change the upper left-hand side “4” into – 44 –.

In the Specification:

On page 15, lines 3-14, please replace the paragraph with the following paragraph:

a1
Compensation films 133 and 233 are interposed between polarizer 13 and 23 and the substrates 20 and 10 respectively. One of the compensation films may be an a-plate compensation film and the other a c-plate compensation film. Otherwise, both the compensation films may be c-plate compensation films. A biaxial compensation film may be used instead of the uniaxial compensation film, and, in this case, the biaxial compensation film may be attached to only one substrate. The slow axis, which is the direction having a largest refractive index, of the a-plate or the biaxial compensation film may be parallel or perpendicular to the polarizing directions of the polarizers 13 and 23.

On page 15, lines 15-20, please replace the paragraph with the following paragraph.

a2
Furthermore, since the protrusions 170 are formed on the color filter 120 and it is not necessary to etch the common electrode (not shown), the manufacturing process of the color filter substrate is simple compared with the first embodiment. In addition, since the lower

A2
cont. substrate does not have protrusions, the manufacturing process of the lower substrate is simple compared with the second embodiment.

On page 16, lines 4-5, please replace the paragraph with the following paragraph.

A3 Now, the third embodiment of the present invention will be described with reference to FIG. 5 showing a pixel having patterns for four domains.

On page 17, line 18 through page 18, line 1, please replace the paragraph with the following paragraph.

A4 The shapes of the patterns are substantially similar to the patterns of the fifth embodiment. That is, a protrusion pattern 170 formed on a color filter substrate and an aperture pattern 270 formed on a TFT substrate have wedge shapes, and the protrusions 170 and the apertures 270 are arranged alternately. The bent portions of the wedge-shaped patterns are placed on the transverse center line passing through the center of a pixel, and have a convex point and a concave point.

On page 25, lines 14-19, please replace the paragraph with the following paragraph.

A5 As shown in FIG. 19D and 19E, a photo-sensitive film such as photoresist or polyimide film is coated on the common electrode 130 with the thickness of 3 to 20 microns, exposed, developed and baked to form a protrusion pattern 170 with 0.3 to 3 micron width. The protrusion pattern 170 may overlap the black matrix 110. Then, a vertical alignment layer 140 is